

## **Oxygen-related defects in germanium**

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# Outline

- VO
  - Electric levels and LVMs
  - Diffusion and dissociation
- Other V-O defects:  $VO^*$ ,  $VO_2$ ,  $VO_2^*$ ,  $VO_2^{**}$
- $IO_2$

# Method-general remarks

- **Cluster: 297 or 501 atoms**  
(the bandgap problem is avoided)
- **Supercells of 216 atoms used for comparison**  
(give lower bound for diffusion energies)
- **Non-linear core correction (NLCC)**  
(to account for the 3d semicore electrons)
- **Diffusion barriers using the Nudged Elastic Band (NEB) method**

## VO

- LVMs predicted using both the cluster and supercell method

exp.	297 cluster	501 cluster	216 supercell
<u>O<sub>i</sub>: 862.9</u>	<u>862.5</u>		<u>839.6</u>
<u>VO<sup>=</sup>: 716</u>	<u>700</u>	<u>694</u>	
<u>VO<sup>-</sup>: 669</u>	<u>688</u>	<u>684</u>	<u>652</u>
<u>VO<sup>0</sup>: 621</u>	<u>646</u>	<u>602</u>	<u>623</u> <u>590</u>

(frequencies in cm<sup>-1</sup>, energies in eV, exper. from Markevich *et al.*)

## VO

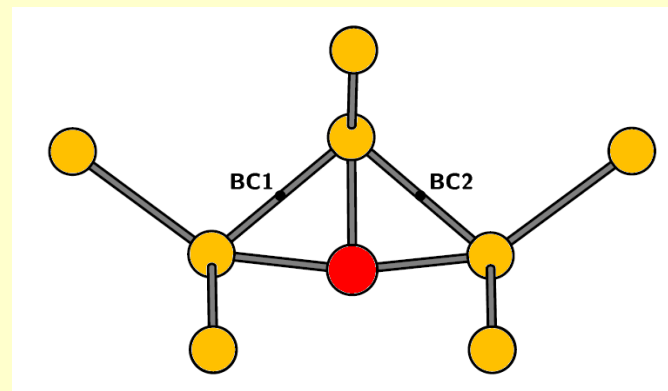
- Electric levels in the supercell are no good: this will be reflected in calculated total energies

exp.	297 cluster	501 cluster	216 supercell
$E_c - 0.26$	$E_c - 0.28$	$E_c - 0.29$	
$E_v + 0.32$	$E_v + 0.41$	$E_v + 0.30$	$E_c - 0.36$
			$E_v + 0.08$

## VO

- Test: hopping of  $O_i$ 
  - supercell: 1.42eV
  - cluster: 2.35eV
  - exper. 2.08eV

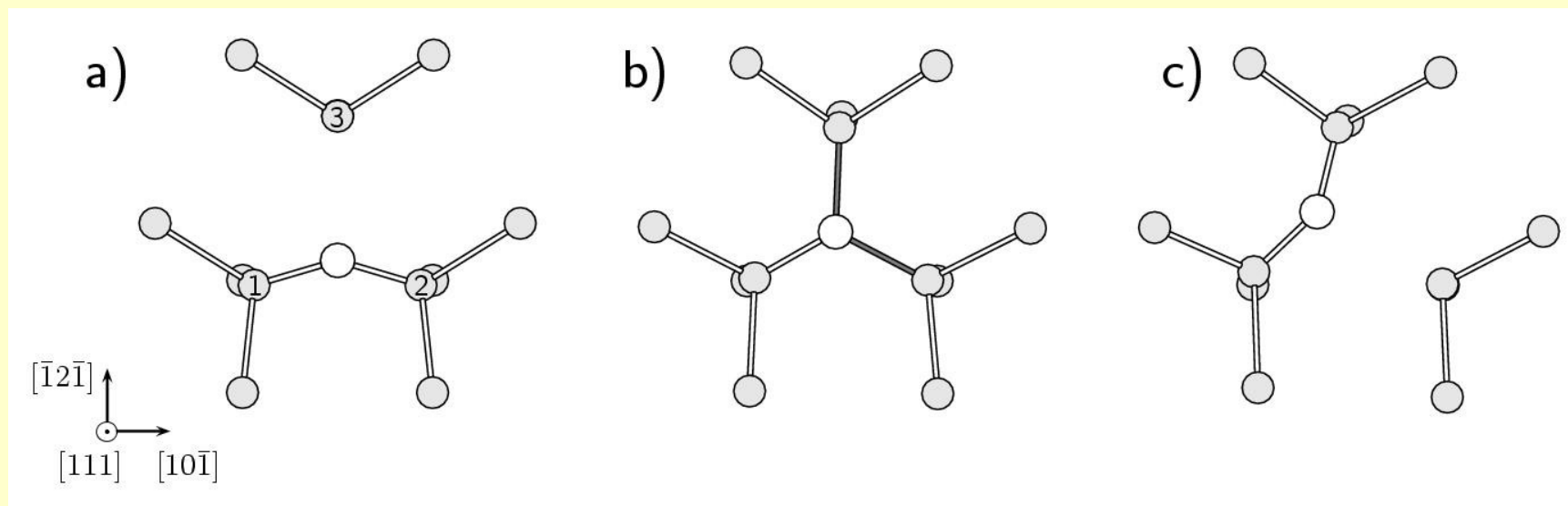
$E_{\text{barrier,sup}} > E_{\text{barrier,cluster}}$  may reflect the gap



- Main limitation of the cluster: calculation of binding energies (interaction with the surface)

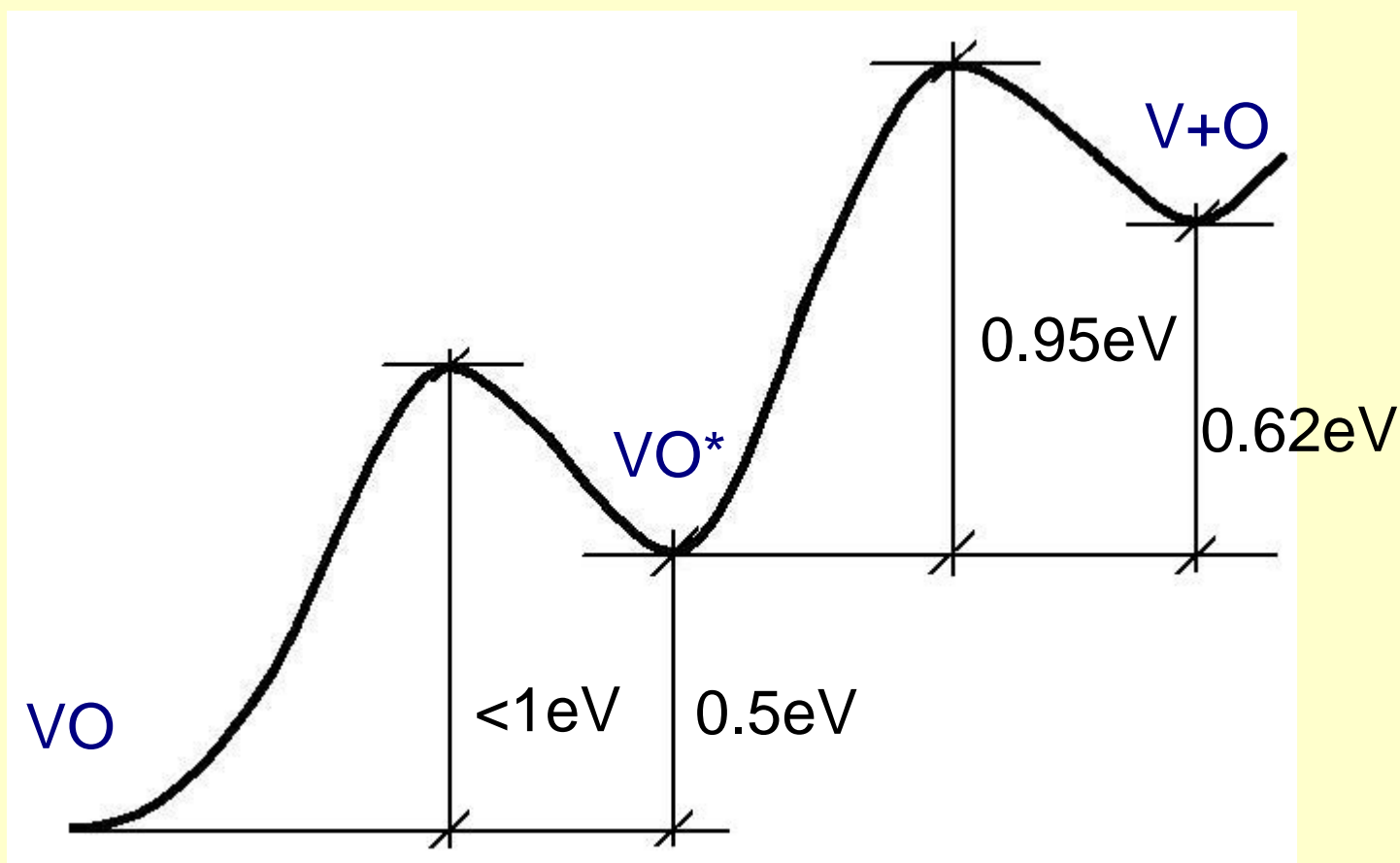
# VO: reorientation

- **calc.:** reorientation barriers are found to be 0.11, 0.23 and 0.40 eV (501 atom clusters)
- **exper.:** no isotope splitting of  $621\text{ cm}^{-1}$  band; No stress alignment of the  $(--/-)$  DLTS peak; No stress splitting of the  $(--/-)$  or  $(-/0)$  DLTS peaks;



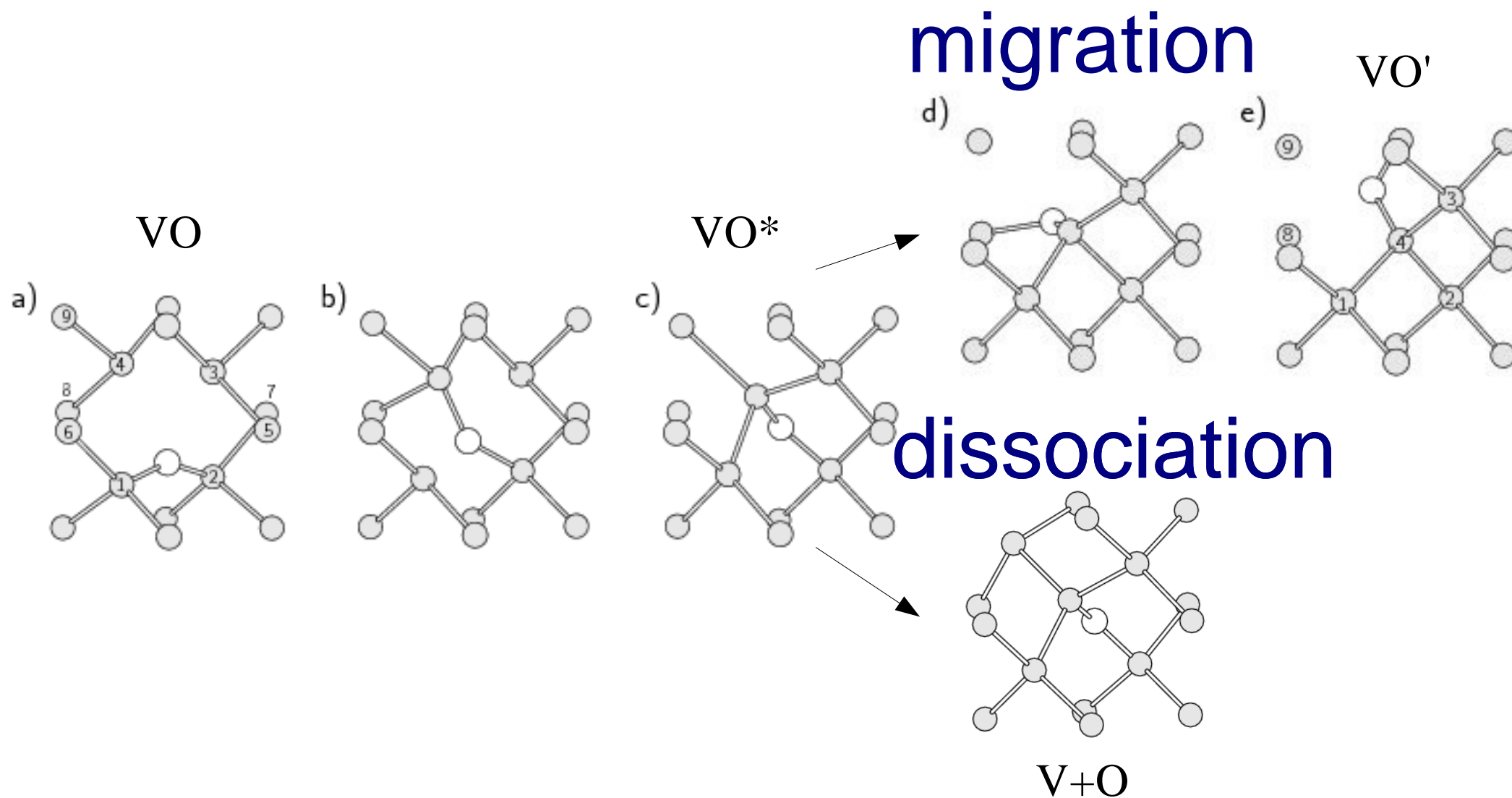
# $VO^0$ : dissociation

Overall barrier: 1.4eV



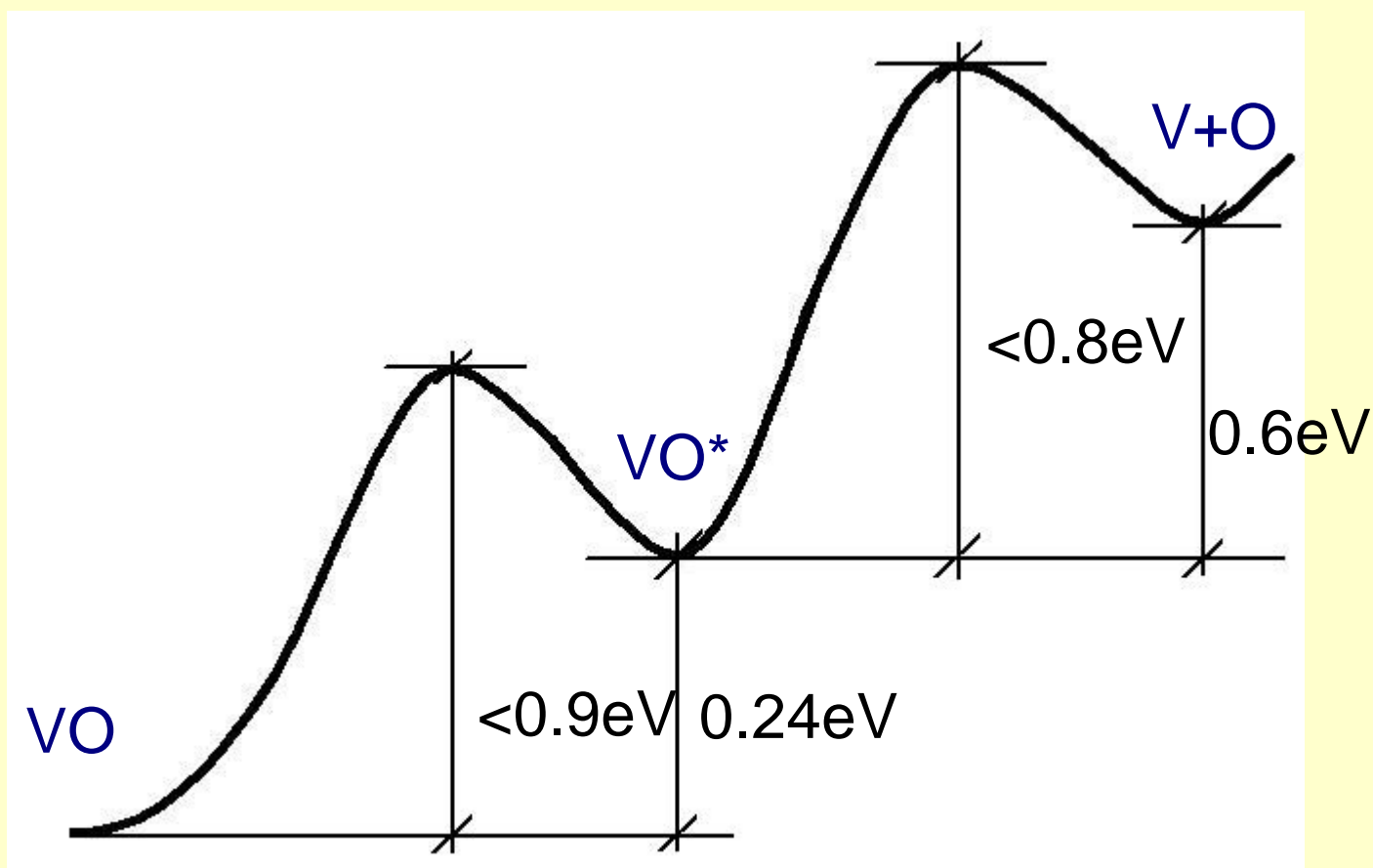


# VO: dissociation and migration

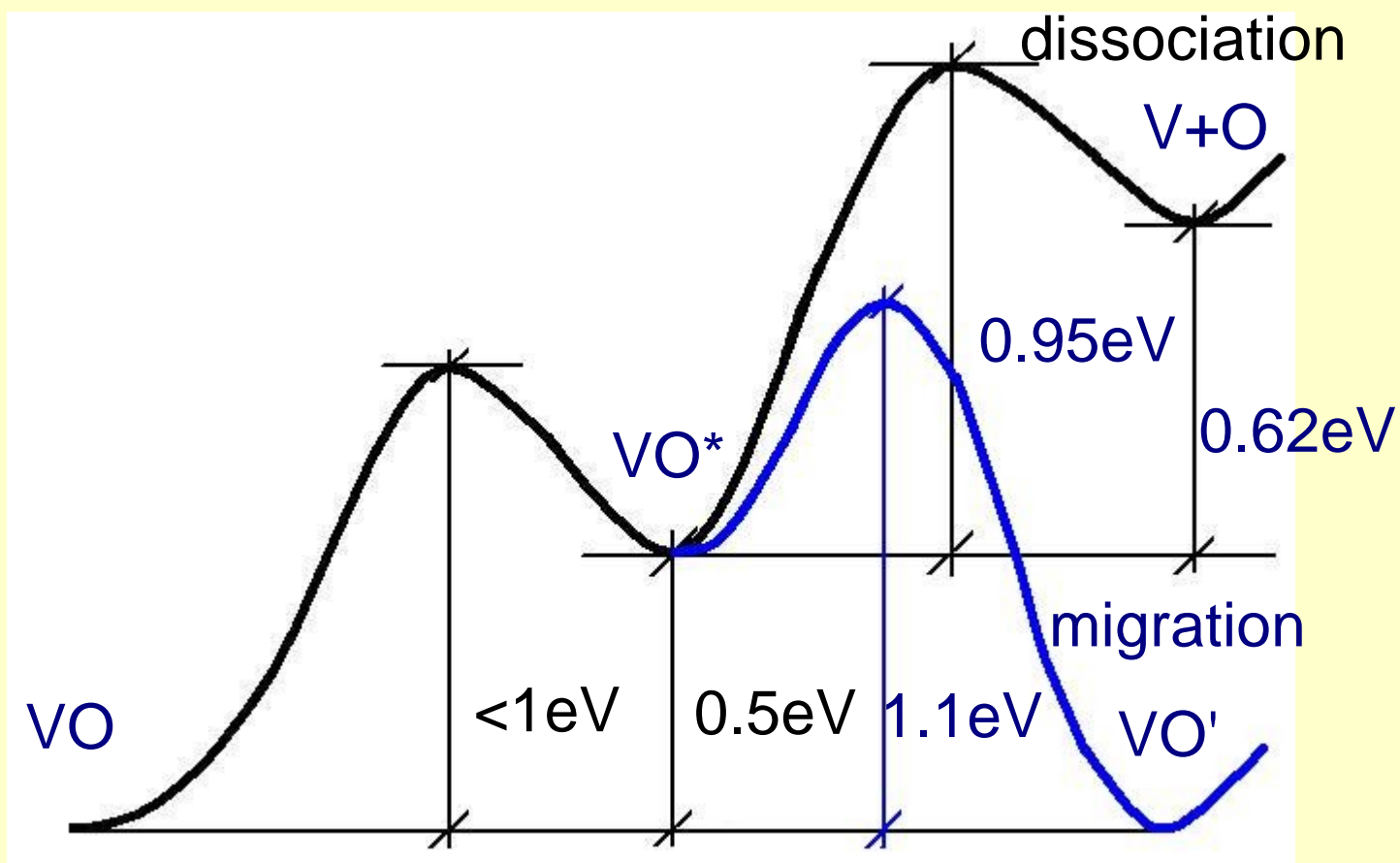


# $VO^-$ : dissociation

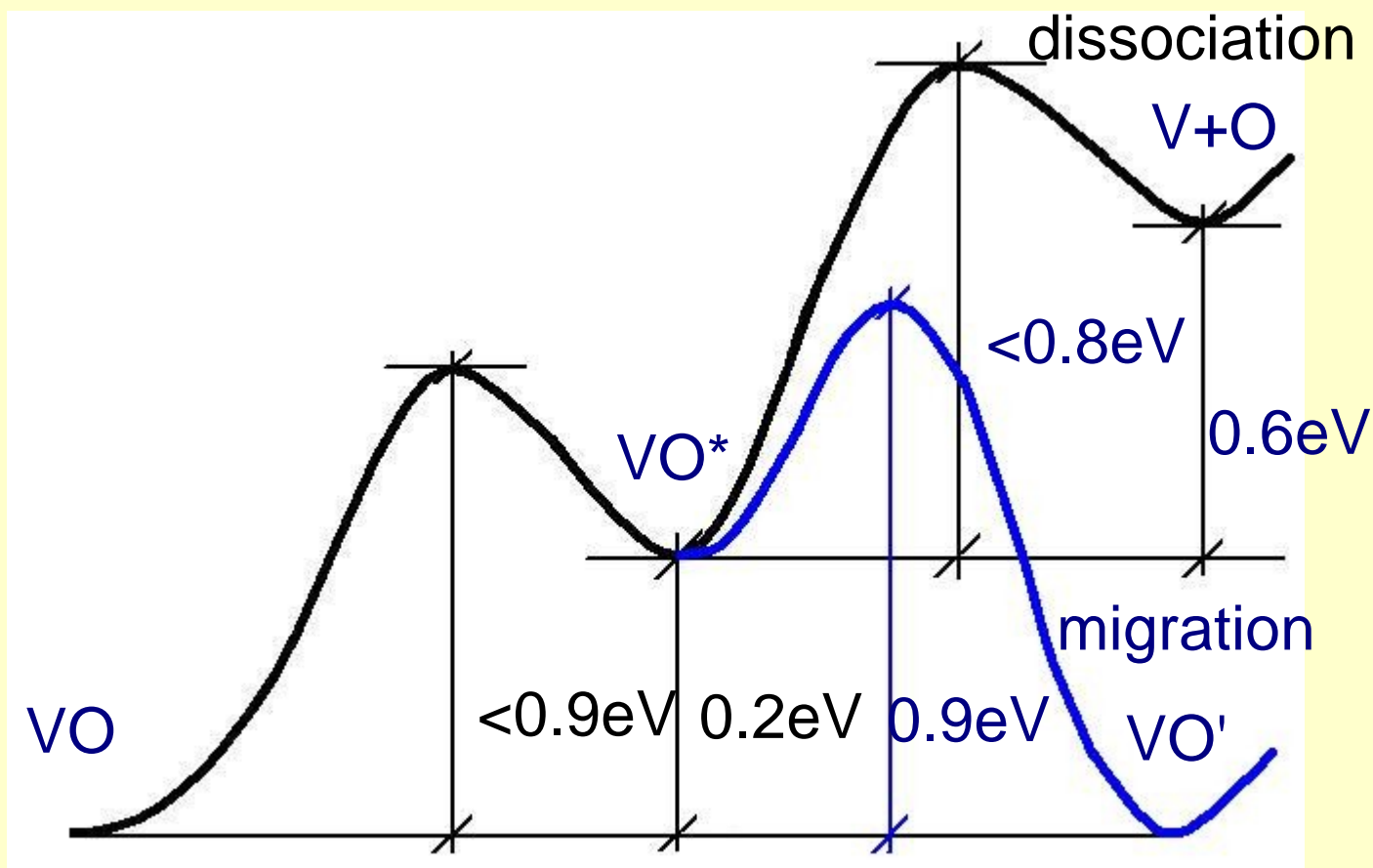
Overall barrier:  $<1$  eV



# $VO^0$ : dissociation



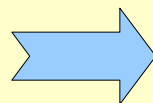
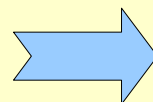
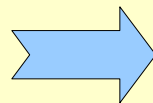
# $VO^-$ : dissociation



# VO - dissociation or migration: linking with experiment

## EXPERIMENT

- Annealing of VO(=/-) DLTS peak in Ge:Bi followed by a growth of BiV  
(Markevich *et al.*, 2006)
- Annealing of VO levels in Hall effect measurements: activation energies and prefactors of 0.9eV and  $10^7\text{s}^{-1}$  for  $\text{VO}^-$  (1.2eV and  $10^{13}\text{s}^{-1}$  for  $\text{VO}^0$ ?)  
(Litvinov *et al.*, 1984)
- Possible formation of  $\text{VO}_2$  after the annealing of VO  
(Litvinov, unp.)



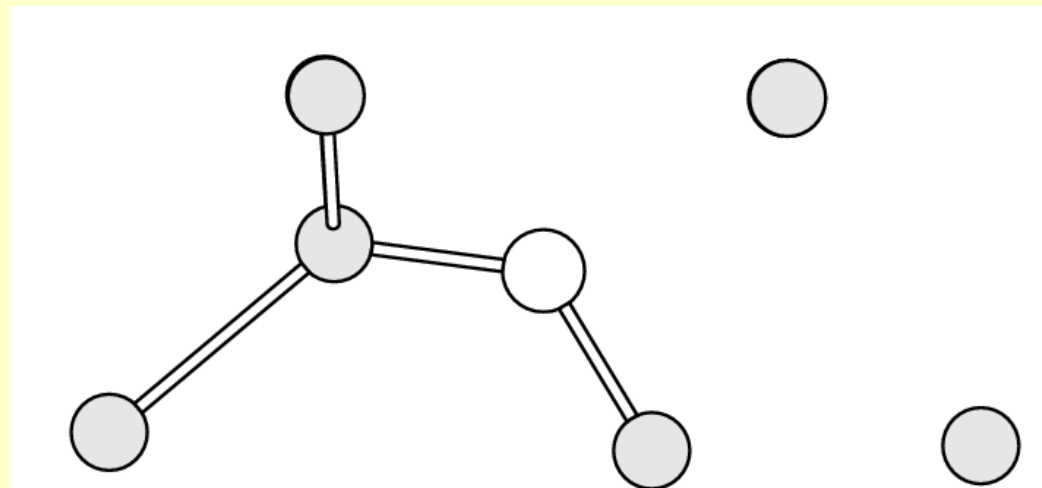
## INTERPRETATION?

VO- dissociates?

v suggest VO- migrates while  $\text{VO}^0$  dissociates?

suggesting migration of VO as a unit?

# VO\*: LVMS

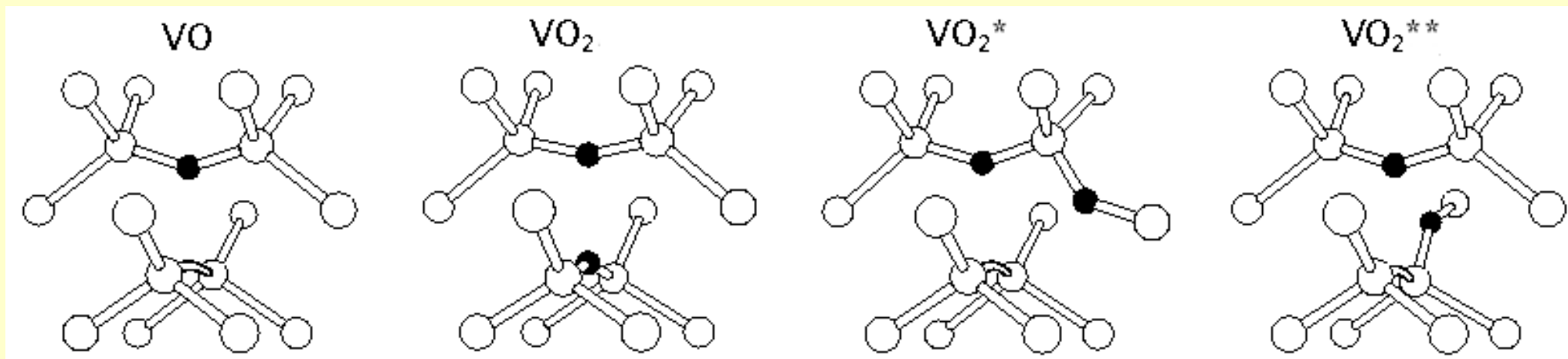


	<b>VO<sup>0</sup></b>	<b>VO<sup>0</sup>(<sup>18</sup>O)</b>	<b>VO<sup>-</sup></b>
297 cluster	704	667 (37)	720 (17)
216 supercell	708	672 (36)	718 (10)
Whan exp.	719	683 (36)	736 (17)

(all in cm<sup>-1</sup>)

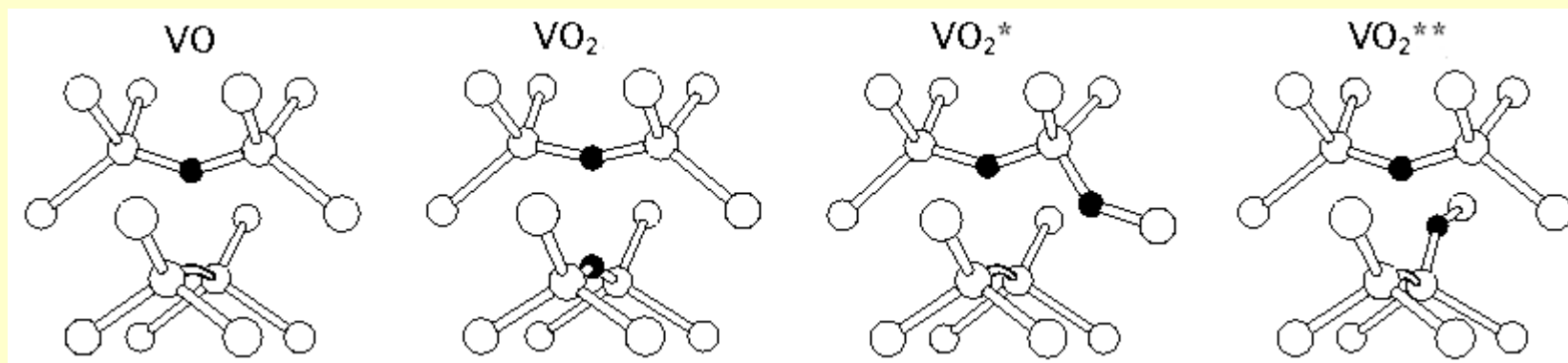
-/0 level at Ev+0.19 eV in a 297 atom cluster (Ev+0.29 eV supercell)

# $\text{VO}_2$ : Structures



# $\text{VO}_2$ : Energetics and electric levels (cluster)

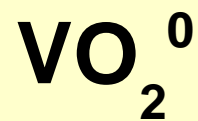
relative energy(eV)	$\text{VO}_2$	$\text{VO}_2^*$	$\text{VO}_2^{**}$
$E_0$	0.00	0.04	0.17
$E_-$	0.59	0.00	0.49



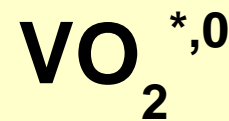
level -/0 at  $E_v+0.40\text{eV}$



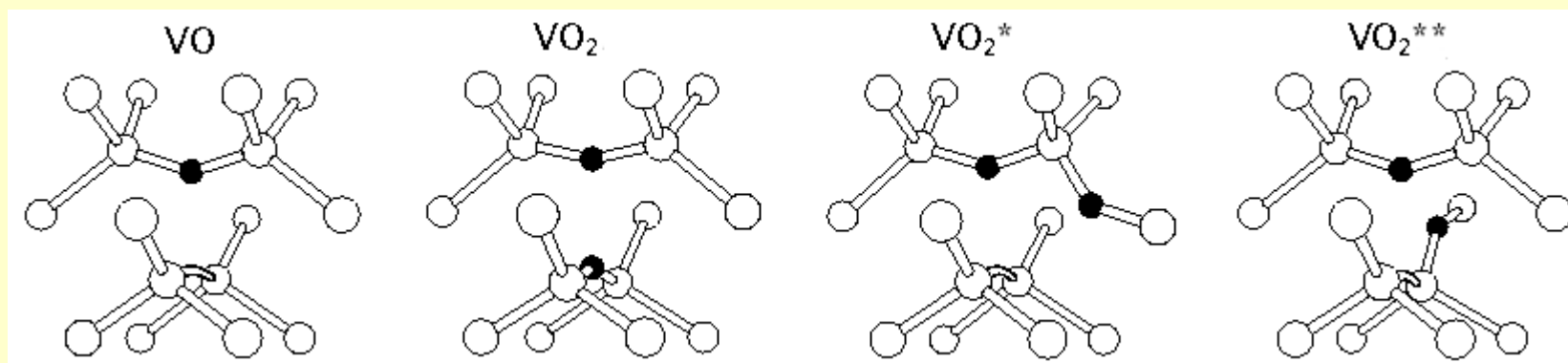
# $\text{VO}_2$ : LVMs (cluster)



707 (2x)



769  
682

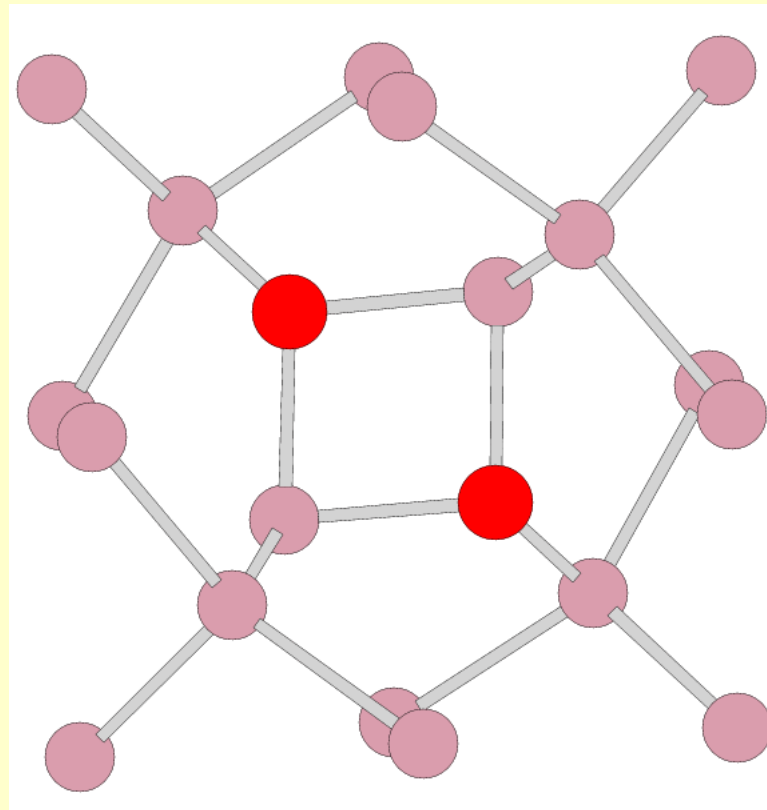
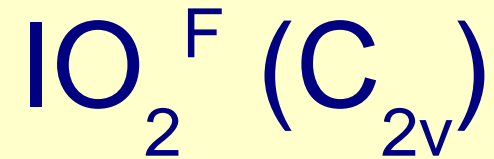


# $\text{IO}_2$ : Energetics and electric levels

relative energy (eV)	-	0	+	$E (-/0)$	$E (0/+)$
$\text{IO}_2^{\text{A}}$		0.91			
$\text{IO}_2^{\text{B}}$		0.68			
$\text{IO}_2^{\text{C}}$	0.64	0.72	0.83		
$\text{IO}_2^{\text{E}}$		1.11			
$\text{IO}_2^{\text{F}}$	<b>0.00</b>	<b>0.00</b>	<b>0.00</b>	$E_{\text{v}}+0.93$	$E_{\text{v}}-0.19$
$\text{IO}_2^{\text{G}}$	1.19	1.16	0.05?		

only one charge state

# $\text{IO}_2$ : Equilibrium structure



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